

Quantum Hall resistances of multiterminal top-gated graphene device

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Four-terminal resistances, both longitudinal and diagonal, of a locally gated graphene device are measured in the quantum-Hall (QH) regime. In sharp distinction from previous two-terminal studies [J. R. Williams *et al.*, Science **317**, 638 (2007); B. Özyilmaz *et al.*, Phys. Rev. Lett. **99**, 166804 (2007)], asymmetric QH resistances are observed, which provide information on reflection as well as transmission of the QH edge states. Most quantized values of resistances are well analyzed by the assumption that all edge states are equally populated. Contrary to the expectation, however, a $5/2$ transmission of the edge states is also found, which may be caused by incomplete mode mixing and/or by the presence of counter-propagating edge states. This four-terminal scheme can be conveniently used to study the edge-state equilibration in locally gated graphene devices as well as mono- and multi-layer graphene hybrid structures.

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I. INTRODUCTION

Landau-level splitting in two-dimensional (2D) electron systems under a perpendicular magnetic field reveals the well-known quantum-Hall (QH) effect.^{1,2} When the Fermi energy is set between two Landau levels, a current circulates along the edge conduction states in a (chiral) direction determined by the carrier type and the direction of the magnetic field.^{2,3,4} Utilizing this chiral character of the edge states one can devise diverse solid-state beam splitters out of 2D electron gas systems.^{5,6,7}

On the other hand, due to the relativistic nature of the carriers, graphene, a 2D honeycomb lattice of carbon atoms, shows the half-integer QH effect.^{8,9,10,11} Thus, the manipulation of the edge states in graphene can be of particular interest. However, the electrostatic deflection of the edge state^{2,5,6,7} is not realizable in graphene due to the Klein tunneling of the carriers through an electrostatic barrier.¹² Nonetheless, the possibility of controlling the edge-state transmission in graphene has been confirmed by locally modulating the filling factor ν and the chiral direction of the edge states.^{13,14} Two-terminal observation of the edge-state transmission in graphene to date is well explained by the complete-mode-mixing hypothesis where all edge states are equally populated at p - n interfaces.^{13,14,15} QH plateaus in two-terminal measurements, however, can be distorted depending on the sample geometry and the contact inhomogeneities.^{16,17} Moreover, the two-terminal conductance gives the information only on the edge-state transmission, lacking the information on the reflection. Thus, for the better manipulation of the edge states of an arbitrary-shaped graphene device, one needs geometry-independent measurements that can furnish information on both the edge-state reflection and transmission.

In this paper, we report on four-terminal QH trans-

port measurements in a top-gated bi-polar graphene device, which show the quantization of longitudinal QH resistances as well as an asymmetry in the diagonal QH resistances (the meaning will be defined below). Our measurement scheme provides precise information on the reflected QH edge states in addition to the transmit-

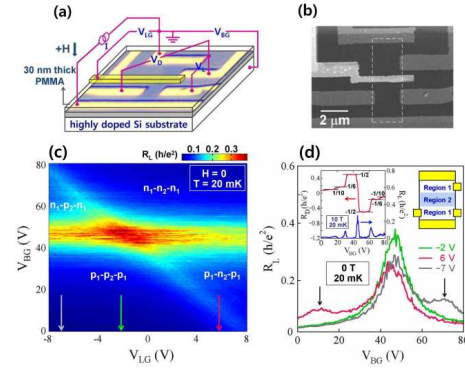


FIG. 1: (Color) (a) Schematic measurement configuration. (b) Scanning electron microscope image of the device after depositing a local gate, the brightest central part. The broken lines represent the graphene edges and the boundary of the PMMA insulation layer is evident by the contrast change near the top of the image. The white scale bar represents 2 μm . (c) Two-dimensional color map of $R_L(V_{LG}, V_{BG})$ for 0 T at 20 mK. A set of carrier types in the regions 1 and 2 is labeled in each quadrant. (d) V_{BG} dependence of R_L at $V_{LG} = -2$ V, 6 V and -7 V extracted from (c) as indicated by arrows with the same color (green, red, and gray, respectively). Left inset: the R_D (upper) and R_L (lower) as a function of V_{BG} at $V_{LG} = -2$ V and 10 T, showing the half-integer QH effect. Right inset: a schematic top view of the device, where the local gate is placed on top of the colored region at the center (the region 2).

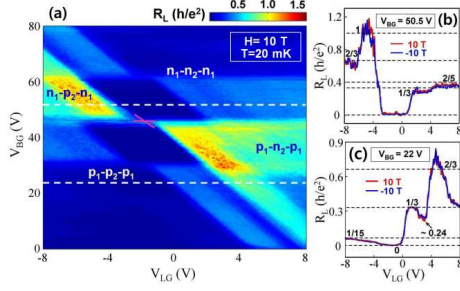


FIG. 2: (Color) (a) Two-dimensional plot of $R_L(V_{LG}, V_{BG})$ for 10 T at 20 mK. A set of carrier types in the regions 1 and 2 is labeled in each quadrant. (b,c) Plots of $R_L(V_{LG})$ extracted from (a) at $V_{BG}=50.5$ V and 22 V, as indicated by the white broken lines in (a). Broken lines represent the calculation result based on the Landauer-Büttiker formula.

ted ones as can be obtained from two-terminal measurements.^{13,14} Most of the results are in good quantitative agreement with the Landauer-Büttiker formula,^{2,4} while unexpected resistance plateaus corresponding to the 5/2 transmission of edge state are also observed. It may arise from the incomplete mode mixing and/or unusual QH edge states that are possibly present under the local gate.^{18,19,20,21,22,23,24} This simple four-terminal scheme will allow an additional insight into the edge-state equilibration in bipolar graphene systems. Results of this study can also be utilized for the spatial manipulation of the Dirac fermions in graphene, which is one of the hot issues in graphene studies.

II. SAMPLE PREPARATION AND VERIFICATION

The sample was prepared by mechanically exfoliating monolayer graphene⁸ on a silicon substrate covered with a 300-nm-thick oxide layer where the silicon substrate was used as a back gate (BG). Electrical contacts of Cr (5 nm)/Au (20 nm) were patterned by the method described elsewhere.²⁵ It was then followed by spin-coating a 30-nm-thick polymethyl methacrylate (PMMA, 950 K, 2% in anisole) dielectric layer on top of the device, which was cross-linked by high doses (15000 $\mu\text{C}/\text{cm}^2$) of electron beams²⁶ with 20 keV. Finally, a local gate (LG) of Cr (5 nm)/Au (40 nm) was deposited at the center of the device [Fig. 1(b)]. The device was cooled down to 20 mK in a dilution fridge (Oxford Instruments, Model AST). The longitudinal ($R_L=V_L/I$) and diagonal ($R_D=V_D/I$) resistances were measured simultaneously with two lock-in amplifiers, synchronized with each other at $I=2$ nA and $f=13.3$ Hz [see Fig. 1(a)].

Figure 1(c) shows a 2D color map of $R_L(V_{LG}, V_{BG})$ measured at zero magnetic field in units of h/e^2 (all resistances will be presented in this unit afterward). In the figure, horizontal and diagonal bands crossing at $(V_{LG}, V_{BG}) \approx (-2 \text{ V}, 46 \text{ V})$ are identified, which divide the

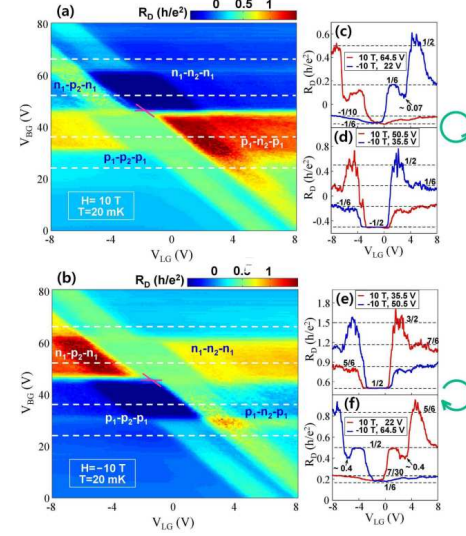


FIG. 3: (Color) [(a) and (b)] Two-dimensional plots of $R_D(V_{LG}, V_{BG})$ at 10 T and -10 T, respectively. A set of carrier types in the regions 1 and 2 is labeled in each quadrant. [(c)-(f)] Red curves: $R_D(V_{LG})$ extracted from (a) at $V_{BG}=64.5$ V, 50.5 V, 35.5 V, and 22 V. Blue curves: $R_D(V_{LG})$ extracted from (b) at $V_{BG}=22$ V, 35.5 V, 50.5 V, and 64.5 V. Thus, (c) and (d) correspond to the *counterclockwise* edge state in the region 1, while (e) and (f) to the *clockwise* edge state in the same region as denoted on the right. The extraction V_{BG} values are marked by the white broken lines in (a) and (b). Broken lines represent the calculation results from the Landauer-Büttiker formula.

map into four different quadrants. These bands represent positions of local resistance maxima arising from the change in the carriers in the region underneath the local gate (the region 2) with respect to the outside region (the region 1) [the right inset of Fig. 1(d)]. Figure 1(d) is the one-dimensional slice plot of $R_L(V_{BG})$ that is extracted from Fig. 1(c) at $V_{LG}=-2$ V, 6 V, and -7 V. It indicates that the position of the secondary resistance peak, corresponding to the diagonal pattern in Fig. 1(c), directly depends on V_{LG} while that of the dominant resistance peak, the horizontal pattern in Fig. 1(c), is almost insensitive to V_{LG} . This leads to a conclusion that the horizontal (diagonal) band is from the charge-neutrality point in the region 1 (in the region 2) where the carrier type is altered. It verifies the successful performance of our bipolar device.^{13,14,26,27,28} Additionally, in the left inset of Fig. 1(d), we show the half-integer QH effect, R_D (upper) and R_L (lower), taken at $V_{LG}=-2$ V and $B=10$ T, indicating that our device consists of a monolayer graphene sheet.^{9,10,11}

III. EXPERIMENTAL RESULTS

The 2D color map of $R_L(V_{LG}, V_{BG})$ measured at 10 T is shown in Fig. 2(a). It displays several skewed blocks

of different resistances, implying the quantization of the longitudinal resistance. Details are more clearly seen in one-dimensional slices, $R_L(V_{LG})$, of Fig. 2(a) for fixed values of V_{BG} . In Figs. 2(b) and 2(c), $R_L(V_{LG})$ is displayed for $V_{BG}=50.5$ V and 22 V, respectively. The red and blue curves were taken at 10 T and -10 T, respectively. Two curves almost completely overlap with each other. Dominant resistance plateaus exist at zero resistance in the region $-3 \text{ V} < V_{LG} < 1 \text{ V}$ [Fig. 2(b)] and $-3 \text{ V} < V_{LG} < 0 \text{ V}$ [Fig. 2(c)], which arise from the full transmission of the edge states when the filling factors in the regions 1 (ν_1) and 2 (ν_2) are identical. In addition to these trivial ones, one also finds plateaus of non-zero fractional resistances such as $1/15$, $1/3$, and $2/3$ in a certain range of V_{LG} . This quantization directly demonstrates that a portion of the edge states is reflected at the interfaces between the regions 1 and 2 for non-identical filling factors ν_1 and ν_2 , which is consistent with the previous two-terminal conductance measurements.^{13,14} The quantized values of R_L are in excellent agreement with the calculation results following Ref. [4] as represented by the broken lines in Figs. 2(b) and 2(c), the details of which will be discussed below.

Now, let us focus on the diagonal resistance R_D , which exhibits far richer features. As seen in Figs. 3(a) and 3(b), the 2D plots of $R_D(V_{LG}, V_{BG})$ taken at 10 T and -10 T, respectively, also reveal skewed blocks of different resistances, but with overall features much different from Fig. 2(a). First of all, both Figs. 3(a) and 3(b) show no inversion symmetry with respect to the crossing point at $V_{BG} \sim 46$ V and $V_{LG} \sim -2$ V, where $\nu_1 = \nu_2 = 0$ (the zero point). Nonetheless, there exists an inversion symmetry between Figs. 3(a) and 3(b), or equivalently a 180° rotational symmetry between them with respect to the zero point, which is in sharp distinction from the feature of R_L [Fig. 2(a)] as well as the previous two-terminal results.^{13,14} More details are revealed by the one-dimensional slices shown in Figs. 3(c)-3(f), which are again extracted from Fig. 3(a) for 10 T (red curves) and Fig. 3(b) for -10 T (blue curves). The corresponding values of V_{BG} are specified in each figure. The figures illustrate that the data taken at 10 T and -10 T are mirror symmetric with respect to $V_{LG} \sim -1$ V, which again confirms the inversion symmetry of R_D between the two opposite field directions.

Figures 3(e) and 3(f) show the R_D measured when carriers in the region 1 are holes ($\nu_1 < 0$) for 10 T and electrons ($\nu_1 > 0$) for -10 T, which corresponds to the *clockwise* edge-states in the region 1. Most of the quantized resistances in these figures match with the inverse of two-terminal conductance observed previously.¹³ Thus, R_D in this region corresponds to the two-terminal (or Hall) resistance of transmitted edge states. In contrast to the two-terminal results, however, Figs. 3(e) and (f) show clear $1/2$ plateaus. This indicates that the disorder effect, which has been regarded as the cause of the observed reduction in the conductance for $\nu_1 = \nu_2 = \pm 2$ in the previous study,¹³ is negligible in this four-terminal mea-

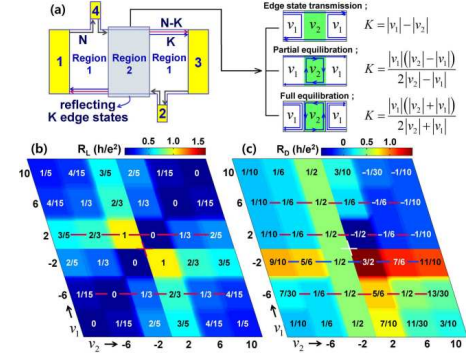


FIG. 4: (Color) (a) Schematic top view of the edge-state configuration. Electrical contacts are shown in yellow and thick arrows represent the chiral direction of QH edge states. The case of the *clockwise* circulation in region 1 is shown as an example. We assume that K out of N edge states are reflected at the interfaces between the regions 1 and 2 (blue arrows). On the right, three possible equilibration processes in a graphene *p-n-p* device and corresponding values of K for each regime are illustrated. [(b) and (c)] Two-dimensional plot of the calculated R_L and R_D for a positive magnetic field as a function of ν_1 and ν_2 . In both figures, calculated values of the resistance plateaus are written at the center of each block in units of h/e^2 . Horizontal lines represent the filling factor ν_1 where one-dimensional data in Figs. 2 and 3 are extracted.

surement. On the other hand, in Figs. 3(c) and 3(d) (for $\nu_1 > 0$ at 10 T and $\nu_1 < 0$ at -10 T), $\pm 1/2$, $\pm 1/6$, and $-1/10$ plateaus are seen together with a sign change at certain values of V_{LG} . This sign change seems to be odd because these plateaus correspond to the *counterclockwise* edge states in the region 1, where R_D is supposed to be negative. A careful analysis, however, indicates that the R_D for $\nu_1 \cdot \nu_2 < 0$ [the n_1 - p_2 - n_1 region in Fig. 3(a) and the p_1 - n_2 - p_1 region in Fig. 3(b)] is nothing but the Hall resistance for the *clockwise* edge states in the region 2, which should be positive as observed. But, still counterintuitive positive ($1/6$) plateaus appear in Fig. 3(c) even for the *counterclockwise* edge states both in the regions 1 and 2 [$\nu_1 \cdot \nu_2 > 0$ for the n_1 - n_2 - n_1 region in Fig. 3(a) and for the p_1 - p_2 - p_1 region in Fig. 3(b)]. This can be accounted for in terms of the Landauer-Büttiker formalism for the edge states as will be shown below.^{2,4}

IV. DISCUSSION

The Landauer-Büttiker formula^{2,4} is suitable for studying the one-dimensional edge-state transport where the current through the lead α (I_α) is expressed as a linear combination of transmission coefficients ($T_{\alpha\beta}$) multiplied by the corresponding chemical potentials (μ_β). Accordingly, it is required to evaluate the scattering matrix (\hat{S}) with the elements $T_{\alpha\beta}$'s and then solve the linear equations ($\vec{I} = \hat{S} \vec{\mu}$), which is straightforward in our case

because the reflection (K) happens at p - n interfaces only [see Fig. 4(a)]. This procedure is adopted to obtain R_L and R_D in Ref. [4] for the configuration that is identical to ours. It is suggested that R_L is finite unless K is zero and R_D has two different values (R_D^+ and R_D^-), depending on the measurement configurations.

$$\begin{aligned} R_{1342} &\rightarrow \frac{h}{e^2} \frac{1}{N-K} \equiv R_D^+, \\ R_{4213} &\rightarrow -\frac{h}{e^2} \frac{N-2K}{N(N-K)} = R_D^+ - \frac{h}{e^2} \frac{2}{N} \equiv R_D^-, \\ R_{1243} &= R_{4312} \rightarrow \frac{h}{e^2} \frac{K}{N(N-K)} = R_D^+ - \frac{h}{e^2} \frac{1}{N} \equiv R_L, \end{aligned} \quad (1)$$

where $R_{\alpha\beta\gamma\delta}$ represents the resistance measured between the voltage leads γ and δ for the current injection from leads α to β . In Eq. (1) it is assumed that N edge states circulate in the *clockwise* direction in the region 1, i.e., $\nu_1 < 0$ (> 0) for 10 T (-10 T) in our case. For a direct comparison with the theoretical expectation,⁴ we adopt a four-terminal schematic sample configuration in Fig. 4(a) rather than a five-terminal one corresponding to the actual device. Since each resistance (R_L or R_D) was obtained in a four-terminal configuration, the schematic is equivalent to the real device configuration, namely, R_D (R_L) in Fig. 1(a) corresponds to R_{1342} (R_{4312}) in Fig. 4(a). Since R_{1342} and R_{4213} depend on the chiral direction of incoming edge states R_D corresponds to R_D^+ (R_D^-) for the *clockwise* (*counterclockwise*) edge states in the region 1. Thus, R_D changes as the sign of ν_1 changes at a fixed magnetic-field direction, but it represents the same resistance if both ν_1 and the magnetic-field direction are altered. This explains the inversion symmetry shown in Fig. 3.

Two-terminal resistance in a bipolar configuration studied previously¹³ corresponds to R_D^+ only in Eq. (1), which is the Hall resistance from the $N-K$ transmitted edge states. It is consistent with our observation shown in Figs. 3(e) and 3(f), which correspond to the *clockwise* edge states in the region 1. But, the information on the reflected edge states is lost in the two-terminal process. On the other hand, R_D^- represents the eliminated Hall resistance by the K reflected edge-states, which can be observed only in a four-terminal configuration. This implies that the average of R_D^+ and R_D^- , $(R_D^+ + R_D^-)/2$, provides the Hall resistance of N incoming edge states (the sign for R_D^- is reversed because R_D^+ and R_D^- are measured in the opposite direction with respect to the current flow). Thus, if more than a half of the incoming edge states are reflected ($2K > N$), R_D^- can change the sign, accounting for the odd sign of resistances seen in Figs. 3(c) and 3(d). On the other hand, R_L indicates the difference between the (two-terminal) Hall resistance of the $N-K$ transmitted and the N incoming edge states which is always positive or equal to zero for $K=0$. In consequence, all the unexpected features in R_D as well as the finite value of R_L are well accounted for at least qualitatively.

For a quantitative analysis, we estimated the number of the reflected edge states (K) in three different regimes:¹³ the edge-state-transmission regime ($\nu_1 \cdot \nu_2 > 0$, $N = |\nu_1| \geq |\nu_2|$), partial-equilibration regime ($\nu_1 \cdot \nu_2 > 0$, $N = |\nu_1| < |\nu_2|$), and full-equilibration regime ($\nu_1 \cdot \nu_2 < 0$, $N = |\nu_1|$). Based on the complete-mode-mixing hypothesis,^{13,15} it is evident that K is equal to $|\nu_1| - |\nu_2|$ in the edge-state-transmission regime, where the extra edge states in the region 1 ($|\nu_1| - |\nu_2|$) are forbidden in the region 2. In the partial-equilibration regime, the excess states ($|\nu_2| - |\nu_1|$) circulate in the region 2 while in partial equilibration with the incoming edge states ($|\nu_1|$). Finally, in the full-equilibration regime, the edge states in the regions 1 ($|\nu_1|$) and 2 ($|\nu_2|$) circulate in opposite directions, propagating in the same direction along the p - n interfaces and equilibrate with each other. In the last two regimes, one can calculate K by using the current-conservation relation.¹³ Schematic edge-state circulation and values of the K are illustrated in the right panel of Fig. 4(a) for each regime. With these values of filling factor in Eq. (1), the R_L and R_D are calculated as functions of ν_1 and ν_2 as shown below.

(a) Edge-state transmission regime:

$$\begin{aligned} R_D &= \begin{cases} \frac{h}{e^2} \frac{1}{|\nu_2|} & (\nu_1 < 0 \text{ at } 10 \text{ T or } \nu_1 > 0 \text{ at } -10 \text{ T}) \\ -\frac{h}{e^2} \frac{2|\nu_2| - |\nu_1|}{|\nu_1||\nu_2|} & (\nu_1 > 0 \text{ at } 10 \text{ T or } \nu_1 < 0 \text{ at } -10 \text{ T}) \end{cases}, \\ R_L &= \frac{h}{e^2} \frac{|\nu_1| - |\nu_2|}{|\nu_1||\nu_2|} \end{aligned} \quad (2)$$

(b) Partial equilibration regime:

$$\begin{aligned} R_D &= \begin{cases} \frac{h}{e^2} \frac{2|\nu_2| - |\nu_1|}{|\nu_1||\nu_2|} & (\nu_1 < 0 \text{ at } 10 \text{ T or } \nu_1 > 0 \text{ at } -10 \text{ T}) \\ -\frac{h}{e^2} \frac{1}{|\nu_2|} & (\nu_1 > 0 \text{ at } 10 \text{ T or } \nu_1 < 0 \text{ at } -10 \text{ T}) \end{cases}, \\ R_L &= \frac{h}{e^2} \frac{|\nu_2| - |\nu_1|}{|\nu_1||\nu_2|} \end{aligned} \quad (3)$$

(c) Full equilibration regime:

$$\begin{aligned} R_D &= \begin{cases} \frac{h}{e^2} \frac{2|\nu_2| + |\nu_1|}{|\nu_1||\nu_2|} & (\nu_1 < 0 \text{ at } 10 \text{ T or } \nu_1 > 0 \text{ at } -10 \text{ T}) \\ \frac{h}{e^2} \frac{1}{|\nu_2|} & (\nu_1 > 0 \text{ at } 10 \text{ T or } \nu_1 < 0 \text{ at } -10 \text{ T}) \end{cases}, \\ R_L &= \frac{h}{e^2} \frac{|\nu_1| + |\nu_2|}{|\nu_1||\nu_2|} \end{aligned} \quad (4)$$

Results for a positive magnetic field (10 T) are summarized in two color maps in Figs. 4(b) and 4(c), respectively, with the calculated resistance labeled in each block. As seen in Fig. 4(b), unless $\nu_1 = \nu_2$, R_L becomes positive and is in good quantitative agreement with the observed results as denoted by the broken lines in Figs. 2(b) and 2(c). The values of R_D are also well reproduced by the calculation as shown in Fig. 4(c) as well as Fig. 3(a). Although not shown, the observed -10 T

data of R_D [Fig. 3(b)] are also well fit by the calculation. Furthermore, for $\nu_1 > 0$ (< 0) at 10 T (-10 T), the calculated R_D becomes positive in the region where $\nu_1 \cdot \nu_2 < 0$ or $|\nu_1| > 2|\nu_2|$ and $\nu_1 \cdot \nu_2 > 0$, reproducing the odd sign of resistances found in Figs. 3(c) and 3(d). Again, all the observed features of R_D are well accounted for in terms of the Landauer-Büttiker formula.^{2,4} Since all of these results are linked to the chiral-directional dependence of R_D , one can conclude that edge states in graphene also behave in the same way as those in a conventional 2D electron gas,² although the QH effect itself is distinct by the Dirac nature of charge carriers.^{9,10,11}

V. 5/2 TRANSMISSION OF EDGE STATES

Most of the observed results in the color maps shown in Figs. 2 and 3 are quantitatively accounted for. However, one can distinguish some additional features which appear as faint diagonal bands crossing from the bottom-right region to the top-left region of the figures in the ranges $V_{BG} > \sim 60$ V and $V_{BG} < \sim 30$ V near the boundary where ν_2 changes sign. In fact, these band structures constitute additional resistance plateaus of ~ 0.24 , ~ 0.07 , and ~ 0.4 as indicated by arrows in Figs. 2(c), 3(c), and 3(f), respectively. Solving Eq. (1) for $R_L \sim 0.24$, $R_D^- \sim 0.07$, and $R_D^+ \sim 0.4$ at $N = |\nu_1| = 6$ gives almost identical K values as ~ 3.54 , ~ 3.52 , and ~ 3.5 , respectively. This indicates that these unexpected resistance plateaus are all produced by a single $5/2$ ($= N - K = 6 - 7/2$) edge-state transmission for $|\nu_1| = 6$, $|\nu_2| = 2$, and $\nu_1 \cdot \nu_2 > 0$, just before ν_2 changes sign or, equivalently, just before the edge-state transmission regime turns into the full equilibration regime. This state may be related to the disorder in the region 2, but no related features are present at $\nu_1 = \nu_2 = \pm 2$ in our measurement.¹³ In addition, the disorder effect is not supposed to be significant in our four-terminal measurement.

Another possible explanation is based on the fact that the plateaus take place near the boundary between the edge-state transmission and the full-equilibration regimes. One may imagine the presence of counter-propagating edge states: for instance, $2 + |\varepsilon|$ *clockwise* edge states and $|\varepsilon|$ *counterclockwise* edge states in the region 2. Here, we expect that $|\varepsilon|$ should be an integer less than 2, because no fractional QH effect is present^{29,30} and the maximum filling factor in the region 2 is two. However, a simple calculation of the total reflection K by adding two different K values for the *clockwise* edge states (edge-state transmission) and the *counterclockwise* ones (full equilibration) leads to $|\varepsilon|$ much larger than 2 (about 4.7, corresponding to $K = 7/2$), which is far from the expectation.

The discrepancy can arise from the incomplete mode mixing for the counter-propagating edge states, which leads to the $5/2$ transmission when only two and a half out of three *clockwise* edge states participate in the equilibration process completely. These counter-propagating

edge states may originate from the compressible and incompressible edge states^{18,19,20} formed near the boundary of the graphene by the charge accumulation as suggested for the graphene sheet placed above a global back-gate.^{19,20} However, the strange diagonal bands observed in our study indicate that the local gate, *by some means, further enhances the charge accumulation*. The presence of the QH ferromagnet states^{21,22,23,24} can also be considered for the counter-propagating edge states. But, the Zeeman energy in 10 T is only about 20 K,²⁴ which is much smaller than the energy difference between the lowest and the first excited Landau levels, ~ 700 K.³¹ Although this phenomenon can be understood by assuming both the incomplete mode mixing and the presence of counter-propagating edge states,^{18,19,20,21,22,23,24} further theoretical and experimental investigation is required for a conclusive account for the effect.

VI. SUMMARY

We studied the edge-state equilibration processes in a locally gated *p-n-p* junction of the graphene by measuring the four-terminal QH resistances. Our scheme enables measurements of finite longitudinal and asymmetric diagonal QH resistances, which furnish precise information on the reflected as well as the transmitted QH edge states. Most of our observations are quantitatively analyzed by the Landauer-Büttiker formula^{2,4} based on the complete-mode mixing hypothesis. But, unexpected resistance plateaus corresponding to the $5/2$ transmission of edge states are also observed. We suggest that it may arise from the incomplete mode mixing and/or the presence of the counter-propagating QH edge states.^{18,19,20,21,22,23,24}

Our simple four-terminal measurement scheme reported here is not sensitive to the contact resistance and the sample geometry, so that it can be conveniently used for the edge-state manipulation of arbitrary-shaped devices such as Mach-Zehnder interferometers.⁷ Moreover, with the additional information on the reflection of the edge states, this scheme enables one to investigate the details of the edge-state equilibration at *p-n* interfaces such as $5/2$ transmission of the edge states found in this study. It can be also employed to investigate the edge states in hybrid structures of mono-layer and multi-layer graphene.^{32,33}

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